

“Thermal behavior of Si-doped fullerenes vs their structural stability at $T = 0\text{ K}$: a density functional study”. Scipioni R, Matsubara M, Ruiz E, Massobrio C, Boero M, Chemical physics letters **510**, 14 (2011). <http://doi.org/10.1016/j.cplett.2011.05.019>